



In re application of

C nfirmation N . 5123

DEC 2 7 2002

Hisashi ISAKA

Docket No. 2002-0382A

TECH CENTER 1600/2900

Serial No. 10/088.265

Group Art Unit 1615

Filed March 18, 2002

Examiner

POLYORTHOESTER AND CURABLE COMPOSITION CONTAINING THE SAME THE COMMISSIONER IS AUTHORIZED TO CHARGE ANY DEFICIENCY IN THE FEES FOR THIS PAPER TO DEPOSIT ACCOUNT NO. 23-0975

## THIRD INFORMATION DISCLOSURE STATEMENT

Assistant Commissioner for Patents, Washington, DC 20231

Sir:

C LANGE TO LANGE Pursuant to the provisions of 37 CFR 1.56, 1.97 and 1.98, Applicant requests consideration of [x] the references listed on attached form PTO-1449 and/or [] the additional information identified below in paragraph 3. A legible copy of each reference listed on the form PTO-1449 and each U.S. patent application listed below is enclosed, except a copy is not provided for each reference previously cited by or submitted to the Patent Office in prior parent application Serial No.

1a. [x] This Information Disclosure Statement is submitted:

> within three months of the filing date (or of entry into the National Stage) of the aboveentitled application, or

before the mailing of a first Office Action on the merits or the mailing of a first Office Action after the filing of an RCE,

and thus no certification and/or fee is required.

1b. [] This Information Disclosure Statement is submitted after the events of above paragraph Ia and prior to the mailing date of a final Office Action or a Notice of Allowance or an action which otherwise closes prosecution in the application, and thus:

- (1) [] the certification of paragraph 2 below is provided, or
- (2) [] the fee of \$180.00 specified in 37 CFR 1.17(p) is enclosed.
- 1c. [] This Information Disclosure Statement is submitted:

after the mailing date of a final Office Action or Notice of Allowance or action which otherwise closes prosecution in the application, and prior to payment of the issue fee, and thus:

the certification of paragraph 2 below is provided, and

the fee of \$180.00 specified in 37 CFR 1.17(p) is enclosed.

- Each item of information contained in this Information Disclosure Statement was cited in a communication from a foreign patent office in a counterpart application and this information was not received by any individual designated in 37 CFR
   1.56(c) more than 30 days prior to the filing of this Information Disclosure Statement. Accordingly, this application is entitled to the protection of 37 CFR
   1.704(d) with reeard to the filing of this Information Disclosure Statement.
- 2. It is hereby certified
  - a. [] that each item of information contained in this Information Disclosure Statement was first cited in any communication from a foreign patent office in a counterpart foreign application not more than three months prior to the filing of the Statement, or
  - b. [] that no item of information contained in the Information Disclosure Statement was cited in a communication from a foreign patent office in a counterpart foreign application and, to the knowledge of the person signing the certification after making reasonable inquiry, was known to any individual designated in §1.56(c) more than three months prior to the filing of the Statement.

- 3. [] Consideration of the following list of additional information (including any copending or abandoned U.S. application, prior uses and/or sales, etc.) is requested.
- For each non-English language reference listed on the attached form PTO-1449, reference is made to:
  - a. [] a full or partial English language translation submitted herewith,
  - b. [] a foreign patent office search report (in the English language) submitted herewith.
  - c. [] the concise explanation contained in the specification of the present application at page.
  - d. [] the concise explanation set forth in the attached English language abstract,
  - e. [] the concise explanation set forth below or on a separate sheet attached to the reference:
- 5. [x] A foreign patent office search report citing one or more of the references is enclosed.

Respectfully submitted,

Hisashi ISAKA

By\_

Matthew Jacob
Registration No. 25,154
Attorney for Applicant

MJ/mc

Washington, D.C. 20006-1021 Telephone (202) 721-8200 Facsimile (202) 721-8250 December 24, 2002

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LIST OF REFERENCES CITED BY APPLICANT SO ATENT A (Use several sheets if necessary)  Date Submitted to PTO: December 24, 2002				Hisashi ISAKA FILING DATE		GROUP TECH CENTER 1600/200	
Date Sub	mitted to	PTO: December 24	, 2002	March 18, 2002		1615	
	-			U.S. PATENT DOCUMENTS	1		
*EXAMINER INITIAL	_	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
	AA	3,515,694	06/1970	Wood			
	AB	3,514,428	05/1970	Wood			<b>S</b>
	AC	4,101,323	07/1978	Buhr et al.		RA	CENTO PO
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		L		FOREIGN PATENT DOCUMENT:			
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	AJ	XP-					
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		отн	ER DOCUMENT(S	(Including Author, Title, Date,	Pertinent Pages, Etc.	<i>)</i>	
	AO	Database Crossfire Beilstein Onlinel Beilstein Institut zur Förderung der Chemischen Wissenschaften, Frankfurt am Main, DE; RN 8001962, 25 January 1999, XP002219980-Abstract of Chen et al.: Tetrahedron, Vol. 54, No. 31, pages 9067-9078 (1998)					
	AP	Database CA Online! Chemical Abstracts Service, Columbus, Ohio, US; DN-114:62063, XP002219981- Abstract of Houghton et al., Synthetic Communications, Vol. 20, No. 16, pages 2387-2400 (1990)					
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EXAMINER				DATE CON	SIDERED		

<sup>\*</sup>EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 608; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.